L	Hits	Search Text	DB	Time stamp
Number				
1	129513	silicon near (layer film)	USPAT;	2004/03/16
1			US-PGPUB;	10:27
1			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
6	82047	remov\$3 near2 heat	USPAT;	2004/03/16
			US-PGPUB;	10:38
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
9	277075	(silicon near (oxide dioxide))	USPAT;	2004/03/16
	1	(sio."sub.2")	US-PGPUB;	10:38
ļ			EPO; JPO;	
			DERWENT;	
1.0	00017		IBM_TDB	0004/00/10
12	22017	SOI (silicon near on near insulator)	USPAT;	2004/03/16
		(silicon-on-insulator)	US-PGPUB;	10:40
			EPO; JPO;	
			DERWENT;	
12	246	/silison noon (loven film) ) and (nomeros	IBM_TDB USPAT;	2004/03/16
13	246	'	,	2004/03/16
		near2 heat) and ((silicon near (oxide	US-PGPUB; EPO; JPO;	10:40
		dioxide)) (sio."sub.2")) and (SOI	DERWENT;	
		(silicon near on near insulator) (silicon-on-insulator) )	IBM TDB	
	<u> </u>	(SIIICOH-OH-IHSUIACOI)	I TOM I DO	<u>                                     </u>